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2 **Dimensional Materials**

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17

18 **Abstract**

19 Nanoblister such as nanobubbles and nanotents formed by two-dimensional (2D) materials have been
20 extensively exploited for strain engineering purposes as they can produce self-sustained, non-uniform in-
21 plane strains through out-of-plane deformation. However, deterministic measure and control of strain
22 fields in these systems are challenging because of the atomic thinness and unconventional interface
23 behaviors of 2D materials. Here, we experimentally characterize a simple and unified power law for the
24 profiles of a variety of nanobubbles and nanotents formed by 2D materials such as graphene and MoS₂
25 layers. Using membrane theory, we analytically unveil what sets the in-plane strains of these blisters
26 regarding their shape and interface characteristics. Our analytical solutions are validated by Raman
27 spectroscopy measured strain distributions in bulged graphene bubbles supported by strong and weak
28 shear interfaces. We advocate that both the strain magnitudes and distributions can be tuned by the 2D
29 material-substrate interface adhesion and friction properties.

30

31 **Keywords:** 2D materials; strain engineering; out-of-plane deformation; interface; membrane theory

32 Two-dimensional (2D) materials are atomically thin crystals with unique properties that lend well to
33 next-generation ultrathin electronic and optoelectronic devices [1-4]. It has been well established that
34 mechanical strain can strongly perturb the band structure of these materials, giving rise to the possibility
35 of using mechanical deformation to tune their electronic and photonic performance dramatically [5-9]. In
36 fact, this principle, termed strain engineering, is now routinely used in manufacturing traditional
37 semiconductor devices [10]. The strain engineering of 2D materials is particularly exciting because an
38 individual atomic sheet is intrinsically capable of sustaining much larger mechanical strain compared to
39 either their bulk counterparts or conventional electronic materials [11,12]. Also, the atomic thickness of
40 2D materials allows them to be easily poked or pressurized from the third dimension (i.e. perpendicular to
41 their plane of atoms) [13-17]. The resulting configurations including nanoscale bubbles and tents can be
42 called by a unified name, 2D material blisters [13-20]. Recently, the considerable strain associated with
43 these nanoblister have created opportunities for the study of new fundamental physics and applications
44 such as enormous pseudo-magnetic fields, large-scale quantum emitters, and so on [21-23].

45 A major challenge in these systems is to find out or even control the strain in the blisters
46 deterministically, calling for understanding and validating how the blister geometry intertwines with
47 mechanics in these atomic sheets [24,25]. So far, self-similar profiles of the 2D material bubbles have
48 been widely discovered in experiments [15,17,26,27]. However, it remains challenging to analytically
49 relate the bubble and tent shape characteristics to the full-field strain distributions and experimentally
50 prove the relation. Consequently, accurate strain tuning through blister shape adjustments is still elusive
51 [21,22,24]. One difficulty comes from the intrinsically nonlinear coupling between in-plane strain and
52 out-of-plane deformations predicted by the membrane theory [28]. More fundamental concern arises from
53 the subtle nature of 2D materials, where the material thickness approaches the atomic scale and the
54 surface is atomically smooth [29]. These features even challenge the applicability of continuum theories
55 from a perspective of deformation physics [30-34]. As a result, the prevailing analysis of the strain
56 distribution and strain-coupled physics and chemistry in 2D material blisters relies heavily on numerical
57 techniques, such as case-by-case molecular dynamics (MD) simulations [22,24,35-37]. To deal with these

58 concerns, a combination of continuum theories with microscale experiments is highly needed and yet to
59 emerge so far.

60 Herein, we experimentally explore the strain field in nanoblisters formed by 2D materials accounting
61 for different natures of 2D materials interfaces. Using tapping mode atomic force microscopy (AFM), we
62 experimentally characterized a variety of bubbles and tents formed by graphene and MoS₂ layers. Their
63 shapes were empirically found to follow a simple power law, enabling closed-form analytical solutions to
64 the Föppl–von Kármán equations at the membrane limit. Our results show that the strain distribution in
65 the 2D material can be estimated by simply measuring the height and radius of the bubbles and tents, and
66 that the strain highly depends on the interfacial interaction between the 2D material and the underlying
67 substrate. To validate our analytical solutions, we experimentally carried out Raman mapping on
68 pressurized graphene nanobubbles with strong (graphene-SiO₂) and weak (graphene-graphene) shear
69 interfaces. The measured and analytically predicted Raman shifts have found good match for both types
70 of interfaces.

71 We first investigate the shape characteristics of both nanobubbles and nanotents of 2D materials,
72 which can form spontaneously or be created in a controllable manner. For the spontaneous case,
73 nanometer-scale bubbles and tents form when monolayer or few-layer 2D materials are exfoliated or
74 transferred on a target substrate. The formation mechanism is typically attributed to the inevitably trapped
75 water, hydrocarbon, and/or nanoparticles at the 2D material-substrate interface during sample preparation
76 [15,17]. The spontaneously formed nanobubbles and nanotents analyzed in this study were made by
77 mechanically exfoliating few- and monolayer graphene and MoS₂ from their bulk crystals on silicon
78 substrate, or transferring CVD-grown MoS₂ on gold or Al₂O₃ substrate [38]. Details on the transfer
79 process for different types of samples are provided in the Methods section [39]. Figure 1a displays typical
80 examples of nanobubbles formed by monolayer graphene on SiO₂. When nanoparticles were trapped, 2D
81 materials can drape around the nanoparticle, forming micro- or nano-tents as shown in Figs. 1b and 1c. To
82 form controllable bubbles, we transferred monolayer graphene and a 4-layer MoS₂ to cover pre-patterned
83 micro-cavities in SiO₂ to form suspended drumheads and then followed a well-established gas diffusion

84 procedure to bulge the drumheads [16]. In this case, the bubbles can be pressurized in a controllable
 85 manner (Fig. 1d [39]).

86 The out-of-plane profiles of all the different types of bubbles and tents prepared by ourselves and
 87 collected from the literature are summarized in Fig. 2. Although the radii of the 2D material blisters range
 88 from tens to thousands of nanometers, we realized that the height profiles of bubbles and tents collapse
 89 onto two master curves if we normalize the out-of-plane deflection (w) of each blister by its central height
 90 (h), and the radial positions (r) by its radius (a). We discovered that the collapsed height profiles can be
 91 described by a unified power form,

$$92 \quad \frac{w}{h} = 1 - \left(\frac{r}{a}\right)^\alpha \quad (1),$$

93 where α is 2 for bubbles or $2/3$ for tents. Note that Fig. 2 summarizes graphene and MoS₂ bubbles and
 94 tents with aspect ratios ranging from 0.05 to 0.20. Remarkably, regardless of the aspect ratios, the types of
 95 2D material, the supporting substrates (silicon, alumina, or atomically flat 2D material flakes), the content
 96 in the bubble (liquid or gas), or the fabrication methods, all bubble profiles can collapse to Eq. (1) with
 97 $\alpha = 2$ (Fig. 2a). We also found that for profiles of graphene and MoS₂ tents, data obtained from MD
 98 simulations or coarse-grained (CG) modeling [22,24,36] can also collapse to Eq. (1) with $\alpha = 2/3$ (Fig.
 99 2b). In fact, the empirical conclusion of $\alpha = 2$ is a widely adopted simple membrane solution for blisters
 100 [48,49] and $\alpha = 2/3$ is well matched with the analytical solution to an indented blister in the literature
 101 [28,50]. We thus conclude that this simple power form can be a good approximation for describing the
 102 profiles of 2D material bubbles and tents.

103 Now that the out-of-plane displacement of 2D material blisters is readily available as given in Eq. (1),
 104 we can try to solve the in-plane displacement and then calculate strains out of displacements. Attributing
 105 to the atomic thinness of 2D materials, it is sufficient to simply use the membrane limit of the Föppl–von
 106 Kármán equations [28,48]. The in-plane equilibrium equation in terms of displacements is therefore:

$$107 \quad \frac{d^2u}{dr^2} + \frac{1}{r} \frac{du}{dr} - \frac{u}{r^2} = -\frac{1-\nu}{2r} \left(\frac{dw}{dr}\right)^2 - \frac{dw}{dr} \frac{d^2w}{dr^2} \quad (2),$$

108 where u is the in-plane displacement of the 2D material and ν is the Poisson's ratio. Plugging Eq. (1) into
 109 this equation and solving the 2nd order ODE using the finite condition when $r \rightarrow 0$ can yield an analytical
 110 solution to the in-plane displacement:

$$111 \quad u = \zeta(\nu) \frac{h^2}{a} \left(\frac{r}{a} - \left(\frac{r}{a} \right)^{2\alpha-1} \right) + u_s \frac{r}{a} \quad (3),$$

112 where $\zeta(\nu) = \frac{\alpha(2\alpha-1-\nu)}{8(\alpha-1)}$ and u_s is a constant related to the slippage at the edge of the blister ($r = a$). This
 113 explicit displacement field allows for the direct solutions for both the radial and circumferential strain
 114 fields:

$$115 \quad \varepsilon_r = \begin{cases} \zeta(\nu) \frac{h^2}{a^2} \left(1 - \frac{1+\nu-2\alpha\nu}{2\alpha-1-\nu} \left(\frac{r}{a} \right)^{2\alpha-2} \right) + \frac{u_s}{a}, & r \leq a \\ -\frac{au_s}{r^2}, & r > a \end{cases} \quad (4a),$$

$$116 \quad \varepsilon_\theta = \begin{cases} \zeta(\nu) \frac{h^2}{a^2} \left(1 - \left(\frac{r}{a} \right)^{2\alpha-2} \right) + \frac{u_s}{a}, & r \leq a \\ \frac{au_s}{r^2}, & r > a \end{cases} \quad (4b).$$

117 Clearly, the sliding of the 2D material-substrate interface ($u_s \neq 0$) can induce non-zero strain in the
 118 supported zone ($r > a$), which is important for strain engineering applications of 2D materials [35].
 119 Typically, the edge of the 2D material blister is assumed to be fully clamped due to adhesion and strong
 120 shear interactions with the supporting substrate outside of boundary [11,22,16]. However, the atomically
 121 smooth surfaces of 2D materials make interfacial sliding particularly easy. Recent experiments on gas-
 122 pressurized graphene bubbles revealed that the shear interactions between graphene and its substrate can
 123 be fairly weak, leading to nonlinear, deflection-dependent interface sliding displacements [14,51]. It has
 124 also been discovered that well-established theories assuming clamped conditions offer good
 125 approximations only when the deflection is small ($h/a < 0.1$), while experimental measurements
 126 deviated from theories with clamped boundaries in samples with large deflection [14]. Recent studies on
 127 2D material interface further highlighted the so-called superlubrication (near-zero friction) when a 2D
 128 material sits on atomically smooth substrates, including itself, which is very common in 2D materials
 129 devices [52].

130 Considering that the graphene and MoS₂ blisters in Fig. 2 encompass either relatively strong
 131 interfaces with small deflections or atomically lubricated interfaces, our prime interest of this study is in

132 two limits: strong-shear limit (clamped, fully bonded interface) and weak-shear limit (sliding, frictionless
 133 interface). For the former, we can apply clamped boundary at the edge of the blister. For the latter, the
 134 stress and displacement in the outer supported region can be obtained as the classical Lamé problem in
 135 linear elasticity [53]. The stress and displacement continuity then leads to [39]

$$136 \quad u_s = \begin{cases} 0, & \text{strong - shear limit} \\ -\frac{\alpha(1+\nu)}{8} \frac{h^2}{a}, & \text{weak - shear limit} \end{cases} \quad (5).$$

137 Now Eq. (4) and Eq. (5) combined offer the complete analytical solutions to the strain field in 2D
 138 materials forming blisters, with either strong or weak interaction with their substrates. After appropriately
 139 choosing the α and u_s according to the specific blister shape and 2D material-substrate interface, one can
 140 easily compute the strain distribution inside and outside of a 2D blister by simply measuring its height
 141 and radius. We note that a generalized analysis may be performed by accounting for the detailed frictional
 142 resistance (e.g. the stick-slip behavior) at the 2D material-substrate interface [54].

143 In Fig. 3, we plot the strain distributions of the 2D material blister as solid curves using our equations.
 144 The strain is normalized by h^2/a^2 such that the distribution will only depend on the interface conditions
 145 and material properties, i.e. the Poisson's ratio. Comparing Fig. 3a for bubbles and Fig. 3b for tents, it is
 146 clear that the strain gradients are much larger in tents, with strain divergence towards the center of the
 147 tents due to the assumed point load. Note that under the same aspect ratio, interface sliding can
 148 considerably reduce the strain level in 2D material blisters in comparison with blisters with strong-shear
 149 interfaces. This highlights the importance of accounting for the ultra-lubricated interface in the case that
 150 the 2D material is supported by an atomically smooth substrate.

151 Next, we try to verify our analytical solutions numerically. We solved the nonlinear Föppl-von
 152 Kármán equations with clamped and slipping boundaries, where the bending behavior is also considered
 153 for generality [39]. The numerical solutions are plotted as markers in Fig. 3 for monolayer graphene with
 154 aspect ratios ranging from 0.05 to 0.20, to directly compare with the analytical solutions (solid curves).
 155 Since analytically solved strains are strictly proportional to h^2/a^2 , after normalization, the solid curves
 156 are no longer dependent on the aspect ratio. However, the numerically solved strains show more

157 complicated dependence on the aspect ratio, because the markers for different aspect ratios do not fully
158 collapse. Despite this small discrepancy, the overall good agreement between the two solutions indicates
159 that for our experimentally observed blisters with aspect ratios ranging from 0.05 to 0.20, bending effects
160 are negligible. Thus, the numerical results have verified that our analytical solution given by Eq. (4) is a
161 reasonable estimation for strains in both bubbles and tents under both clamped and slipping boundary
162 conditions.

163 Our analytical solution, though verified numerically, is still challenged by a widespread concern on
164 the breakdown of classical membrane theories at the atomic limit [30-34]. To examine the applicability of
165 our analytical solutions, we performed graphene bulging experiments with intentionally designed strong-
166 and weak-shear interfaces. Monolayer graphene sealed micro-cavities were fabricated by
167 micromechanical cleavage of graphene over SiO₂ substrate with pre-patterned 2.5-micron-radius holes
168 (Fig. 4a). Following a well-developed gas diffusion method [16], we can create a pressure difference
169 across the monolayer and bulge it in a controlled manner.

170 The strong-shear-interface graphene bubble was generated by pressurizing a graphene monolayer on
171 SiO₂ with the maximum deflection less than 150 nm. Under this condition, the interface sliding was found
172 to be minimal, thus is compatible with the clamped interface assumption [14]. To experimentally study
173 the weak-shear case, we assembled a graphene-SiO₂ supporting substrate for the graphene bubble (Fig.
174 4b). First, few-layer graphene was transferred over a SiO₂ micro-hole. The suspended portion of the
175 multilayer graphene was then etched to open up the micro-hole. After creating an atomically flat region
176 around the micro-hole, a monolayer graphene was precisely transferred to cover this micro-hole, resulting
177 in a graphene drumhead supported by few-layer graphene [39]. Applying a differential pressure across the
178 suspended graphene membrane, this graphene bubble was expected to bulge under weak-shear interface
179 as the graphene-graphene interface can be considered as superlubricated.

180 We performed multiple AFM and Raman characterizations on the graphene bubbles with well-
181 controlled interfaces [39]. For an axisymmetric graphene bubble, the G band shifts in the Raman
182 spectrum are related to the strain components through the following equation [55]:

183
$$\frac{\Delta\omega_G}{\omega_0} = -\gamma(\varepsilon_r + \varepsilon_\theta) \pm \frac{\beta}{2}(\varepsilon_r - \varepsilon_\theta) \quad (6),$$

184 where ε_r and ε_θ are analytically expressed in Eq. (4), γ is the Grüneisen parameter, and β is the shear
 185 deformation potential that details the amount of splitting in the G bands, which were experimentally
 186 calibrated for monolayer graphene ($\gamma = 1.99$ and $\beta = 0.99$) [56]. Therefore, analytical prediction for
 187 strain fields can be readily converted to analytical prediction for the G band shifts using Eq. (6).
 188 Particularly, at the center of the bubble where $\varepsilon_r = \varepsilon_\theta$, the G band shifts are predicted by Eq. (4) and Eq.
 189 (6) to take a very simple form:

190
$$\Delta\omega_G = -c\gamma\omega_0 \frac{h^2}{a^2} \quad (7)$$

191 where the constant c is $\frac{3-\nu}{2}$ for bubbles supported by strong shear interfaces and is $(1-\nu)$ by weak shear
 192 interfaces.

193 Due to space limitations, we present the details of the experimental Raman characterizations in
 194 Supplemental Materials Note 2 [39]. Here, we first show the Raman G band shifts at the center of
 195 graphene bubbles as a function of h^2/a^2 in Fig. 4c, which is predicted to be linear by our analytical
 196 solution in Eq. (7). The markers represent experimental data for both SiO₂- (brown) and graphene-
 197 supported (green) graphene bubbles and the solid curves correspond to predicted G band shifts for strong-
 198 (green) and weak-shear-interfaced (brown) 2D material bubbles. By setting the Poisson's ratio of
 199 graphene to be 0.165 in Eq. (7), we find good agreement between our theoretical predictions and
 200 experimental measurements. This may confirm the applicability of our simplified membrane theory in
 201 relating the out-of-plane deformations to in-plane strains for 2D material blisters.

202 In Fig. 4d, we further normalize both the measured and predicted G band shifts by h^2/a^2 and plot
 203 them as functions of the normalized radial position r/a . Our weak-shear and strong-shear model can
 204 partially capture the full-field strain distribution in graphene-on-graphene and graphene-on-SiO₂ bubbles,
 205 respectively. However, deviation between predicted and measured G band shifts occurs and enlarges
 206 towards the edge of the bubble, especially for SiO₂-supported graphene bubbles. We attribute such edge
 207 deviation in Fig. 4d to the limited spatial resolution of Raman spectroscopy ($\sim 1 \mu\text{m}$) and the possible
 208 doping effect by the substrate [57,58], which are further elucidated in Fig. S9 and S10 [39]. As for 2D

209 material tents, a recent study reported the Raman 2D band shifts for a SiN/Si-supported graphene
210 drumhead subjected to nanoindentation [59]. The experimental results can be well captured by our
211 analytical solution to 2D material tent with strong-shear interface (Fig. S11 [39]). We thus claim that our
212 analytical solutions in Eq. (5), enabled by the shape characteristics in Fig. 2, can offer valid estimation for
213 the in-plane strain in 2D material bubbles and tents simply by knowing their height and radius. It is
214 especially true at the center of bubbles by Eq. (7), which may, in turn, be used to measure the Gru□neisen
215 parameter for the broadly extended 2D material family.

216 The 2D material bubble and tent structures have been exploited in many recent studies [17-22,27,60-
217 64], where people typically use pre-patterned micro-pillars or interface-confined contents to produce a
218 single or an array of 2D material blisters. Our findings show that the strain in blisters highly hinges on
219 their aspect ratio (h/a). We note that a balance between adhesion (which favors large areas of contact)
220 and stretching energy (which diminishes in blisters of large radius) dictates a constant aspect ratio:

$$221 \quad h/a = (\phi\Delta\gamma/E_{2D})^{1/4} \quad (8).$$

222 where $\Delta\gamma$ is energy change per unit area, E_{2D} is the in-plane stiffness of the 2D material, and ϕ is a
223 constant prefactor. Equation (8) implies that the aspect ratio or ultimately the strain of a 2D material
224 bubble or tent is dominated by the ratio of the 2D material-substrate adhesion to the in-plane stiffness of
225 the 2D material. In fact, this interface- and stiffness-dependent out-of-plane deformation characteristic has
226 been observed at a variety of length scales — from graphene to polymer films with thicknesses ranging
227 from 1 nm to 1 mm [50]. Here, we determine ϕ for 2D material bubbles and tents of both strong- and
228 weak-shear interfaces in Table 1 [39]. Notably, recent experimental discovery of the constant aspect ratio
229 of 2D material bubbles for a given 2D material-substrate system provided a good validation [17], and
230 there is no available experimental data for 2D material tents so far.

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233

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236

237 **Figure Captions**

238

239 **FIG. 1.** From top to bottom: atomic force microscopy (AFM) phase and height images of spontaneously
 240 formed graphene bubbles on SiO₂ (a), a multilayer graphene tent on SiO₂ (b), and a CVD-MoS₂ tent on
 241 gold film (c). (d) From left to right: optical image of graphene flakes exfoliated on pre-patterned SiO₂
 242 with micro-cavities, AFM height images of a monolayer graphene bubble, and a 4-layer MoS₂ bubble.
 243 Note that (S) represents bubbles or tents formed spontaneously while (P) represents those formed by
 244 controllable air pressurization. The unit for all height bars is nm.

245

246 **FIG. 2.** Universal shape characteristics of 2D material bubbles and tents. (a) Normalized bubble profiles
 247 measured by our experiments and collected from literature. Note that samples from Ref. [17] feature
 248 atomically smooth interfaces, are labeled by *. (b) Normalized tent profiles measured by our experiments
 249 and simulation results in the literature. The simulation data about graphene and MoS₂ is from Ref. [36]
 250 and Ref. [24], respectively.

251



252 **FIG. 3.** Normalized strain distribution curves predicted by our analytical solution (solid lines) and solved
 253 by numerical analysis (markers) in bubbles (a) and tents (b), subjected to both clamped (strong interface)
 254 and frictionless (sliding interfaces) boundary conditions. The strain is normalized by h^2/a^2 , giving rise to
 255 deflection-independent curves. The numerical results are solved for a monolayer graphene with aspect
 256 ratios ranging $0.02 < h/a < 0.2$.

257

258 **FIG. 4.** Schematics of the graphene drumheads formed on a SiO₂ substrate (a) and on a graphene-covered
 259 SiO₂ substrate (b). (c) Raman shifts of the G band at the center of graphene bubbles predicted by our
 260 analytical solution (solid curves) and measured by our experiments (markers). (d) Normalized Raman
 261 shifts of the G band ($\Delta\omega_G a^2/\omega_0 h^2$) as functions of the normalized radial position (r/a) for monolayer
 262 graphene bubbles.

263

264

Table 1. The prefactor ϕ that determines the aspect ratio by $\Delta\gamma/E_{2D}$ in Eq. (8).			
Shape		Strong shear	Weak shear
Bubble		$\frac{24(1-\nu)}{5(7-\nu)}$	$\frac{6}{5}$
Tent		$\frac{72(1-\nu)}{5-3\nu}$	18

265

266

267

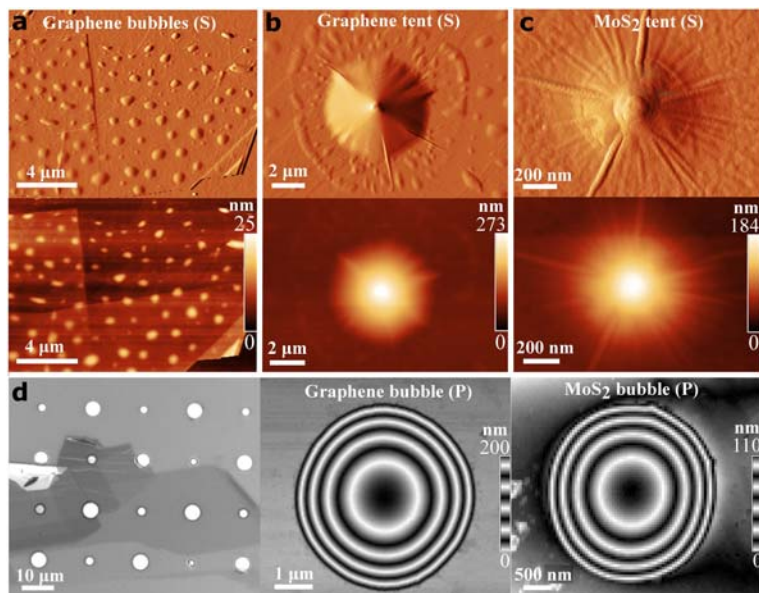
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Figure 1

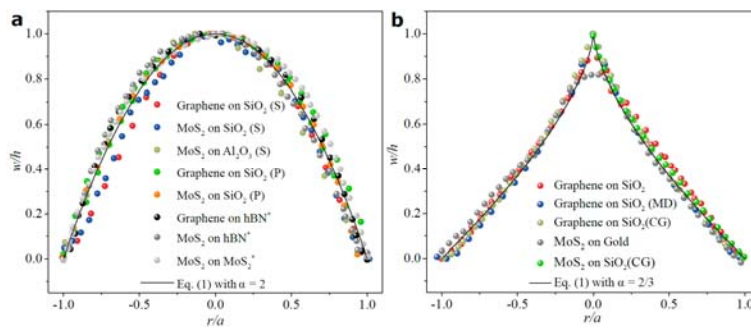


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Figure 2

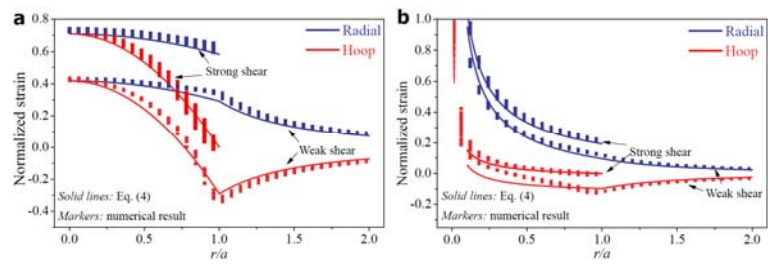


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Figure 3

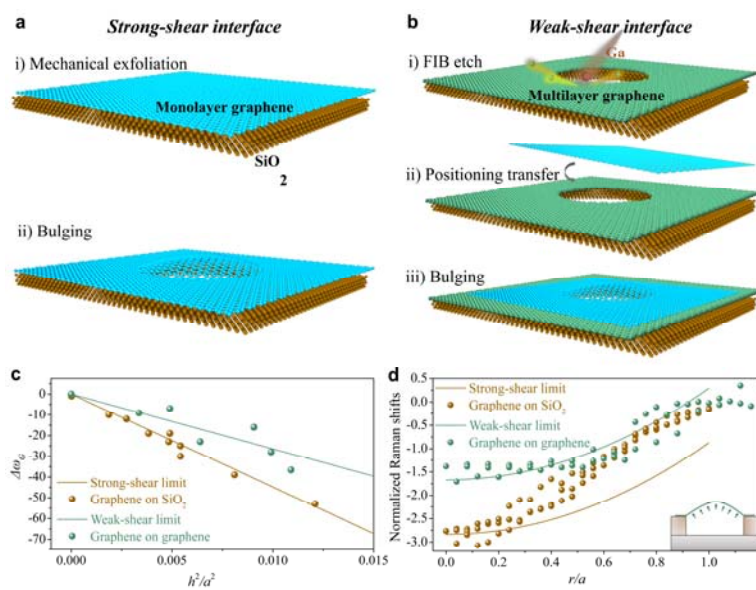


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Figure 4



281

282

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